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# H<sub>2</sub>S chemical looping selective and preferential oxidation to sulfur by bulk

#### $V_2O_5$

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#### Abstract

The concept of chemical looping is applied for the first time to selective oxidation of H<sub>2</sub>S to elemental sulfur. An oxygen carrier (OC) is exposed to cyclic reduction by H<sub>2</sub>S and oxidation by O<sub>2</sub>. The properties of bulk V<sub>2</sub>O<sub>5</sub> as OC are explored for this reaction in the 150-200 °C temperature range. Steady cyclic behavior can be obtained with high selectivity towards elemental sulfur. Some undesired SO<sub>2</sub> is formed during exposure to H<sub>2</sub>S but more significantly during re-oxidation of the OC. This indicates that bulk V<sub>2</sub>O<sub>5</sub> does not completely oxidize the adsorbed H<sub>2</sub>S in the reductant step. Characterizations indicate that V<sup>4+</sup> and V<sup>5+</sup> species are mostly involved in the process. Preferential oxidation in presence of CH<sub>4</sub> is confirmed on this OC. Although optimization needs to be done, the potential of chemical looping concept for direct preferential oxidation of H<sub>2</sub>S in natural gas and biogas is demonstrated.

#### 1.Introduction

Removal of sulfur-containing compounds is one of the main issues in the fuel industry. H<sub>2</sub>S is one of the significant compounds to be considered as gasoline or diesel desulfurization processes generate a large amount of this gas. Natural gas and biogas also contain large amounts of H<sub>2</sub>S (tens to hundreds of ppm), which must be removed before the fuels can be used as energy sources or chemical feedstock.

The Claus process is a well-known process for converting H<sub>2</sub>S to elemental sulfur at a large industrial scale [1]. However, the recovery of sulfur in the Claus process is not complete due to the overall limitation of thermodynamic equilibrium leading to only 95-97 % of sulfur recovery. To remove the residual H<sub>2</sub>S, various processes of additional purification are needed. Therefore, this process is uneconomical for small plants and not suitable for gas streams with low concentrations of H<sub>2</sub>S. Furthermore, in the case of natural or biogas treatment, H<sub>2</sub>S needs to be separated from the mainstream before being processed. The most attractive method to treat the H<sub>2</sub>S is the selective catalytic oxidation of H<sub>2</sub>S to elemental sulfur (Eq. 1).

$$H_2S + \frac{1}{2}O_2 \to \frac{1}{n}S_n + H_2O$$
 Eq. 1

As H<sub>2</sub>S selective oxidation to elemental sulfur is an exothermic reaction, this reaction is irreversible and does not have any equilibrium limitations contrary to the Claus process. Yield towards elemental sulfur is usually limited by SO<sub>2</sub> which can be formed as a major by-product depending on the ratio of H<sub>2</sub>S to O<sub>2</sub>, reaction temperature and catalyst efficiency. Side reactions, such as elemental sulfur deposition or deactivation of the active phase, are generally responsible for the alteration of sulfur yield with time. To avoid sulfur deposition inside the catalytic reactor, reaction needs to be performed above 150-180 °C. Different

vanadium-based catalysts have already been studied in the past [2-5]. In particular, bulk  $V_2O_5$  phase has been reported to have a better performance than other bulk oxides like magnesium oxide, bismuth oxide, and molybdenum oxide, iron oxide [6-8].

Vanadium oxide catalysts have been extensively studied for many hydrocarbon oxidation reactions, mostly as supported catalysts, for example by Wachs et al. [9, 10]. Characterization studies have revealed that the deposited vanadium phase contains two-dimensional surface vanadium along with V<sub>2</sub>O<sub>5</sub> crystallites above monolayer coverage. Vanadium catalysts also show important redox properties and ability to react at low temperature. The reactivity properties of the supported vanadium catalysts were compared with the structural properties of the dehydrated surface V<sup>5+</sup> species rather than the dehydrated reduced surface vanadia V<sup>4+</sup> and V<sup>3+</sup> species. Apart from this, the importance of the role of the terminal V=O bond as well as that of bridging V-O-V bond was shown in the case of selective oxidation of hydrocarbons. The surface concentration of bridging V-O-V bonds increases with vanadia coverage due to the increase in the ratio of polymerized to isolated vanadia species. Doping of the vanadium catalysts by various metals like Mo, La, Cu, Ce has been studied in detail [8,11-14] and showed the effect of these metals on the vanadium species and hence on the activity and selectivity of the catalysts.

Chemical looping (CL) processes attract increasing interest with time to understand and implement this concept in different oxidation reactions. CL processes involve an oxygen carrier, which is reduced in the presence of a reductant and produces the desired product. Subsequently, the exposure of the reduced solid to an oxidant allows the carrier re-oxidation and regeneration. Although many of the elementary steps involved in CL operations are similar to catalytic reactions (reactant adsorption, surface reactivity, product desorption), it

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should be emphasized that the oxygen carrier material acts as an actual reactant and not as a catalyst [15]. For CL, original reactor systems are necessary with respect to classical co-feed fixed (or fluidized) bed reactors. For solid oxygen carriers and gas phase reactants, CL generally involves the use of circulating fluidized bed systems [16] or fixed bed switching reactors. For the experimental studies in the laboratory scale, the fixed bed reactor which is fed alternatively with the gas reactants is usually the most appropriate while circulating bed reactor systems are better adapted for industrial applications as already used in Fluid Catalytic Cracking (FCC) for example [17,18].

Although CL processes have been studied for several reactions of industrial interest by Löfberg et al. [19], Bhavsar et al. [20], Ma et al. [21] or Pachler et al. [22], for example. To our knowledge, the concept of CL oxidation of H<sub>2</sub>S to elemental sulfur has never been proposed. It consists of separating Eq. 1 in two distinct steps:

 $H_2S + OC_{ox} \rightarrow S + H_2O + OC_{red}$  Eq. 2

 $OC_{red}$  +  $\frac{1}{2}O_2 \rightarrow OC_{ox}$  Eq. 3

Where "OC" represents the oxygen carrier.

Such an approach could offer important advantages with respect to direct, co-feed, oxidation reaction:

 provided an appropriate OC carrier is developed, selectivity could be improved by avoiding direct interaction between adsorbed sulfur species and di-oxygen from the gas phase or adsorbed on the surface of the material and favoring the reactivity of lattice oxygen species;

- eventual sulfur species deposited on the surface of the carrier could be removed during regeneration step thus limiting the deactivation of the process;
- no mixing of H<sub>2</sub>S and O<sub>2</sub> can improve the safety of the process and enlarge considerably the range of H<sub>2</sub>S concentrations which may be considered, including even pure H<sub>2</sub>S;
- depending on the reactivity of the oxygen carrier material and reaction conditions, oxidation of H<sub>2</sub>S could be performed in the presence of other combustible gases such as methane.

In this last case, if preferential oxidation of H<sub>2</sub>S is achieved in the presence of methane, then the direct purification of natural or bio-gas could be performed without the need for prior separation of H<sub>2</sub>S. This would constitute a significant breakthrough in natural and bio-gas treatment.

The key to such development is in the oxygen carrier, which needs to fulfill specific requirements. It should have:

- high reactivity in both the H<sub>2</sub>S oxidation and the regeneration steps;
- good selectivity for the desired oxidation product, i.e. elemental sulfur;
- good stability over many of redox cycles;
- good resistance towards sulfur deposition and removal.

For industrial implementation of the process, other properties will obviously be required, such as good mechanical resistance in circulating bed systems. As reminded,  $V_2O_5$  is well known for its redox properties and catalytic reactivity for  $H_2S$  oxidation [2,23-24]. For this reason, bulk  $V_2O_5$  was chosen as OC to explore this new approach towards  $H_2S$  oxidation by chemical looping.

In a first step, the thermodynamics of the system are considered to check the feasibility of operating in CL mode for this reaction using  $V_2O_5$ . Then the reactivity of the carrier is studied versus temperature and exploring different H<sub>2</sub>S concentrations and H<sub>2</sub>S:O<sub>2</sub> ratio. Finally, the chemical looping is performed in presence of methane to check if preferential oxidation of H<sub>2</sub>S can be achieved.

#### 2. Experimental section

#### **2.1** Carrier synthesis

Vanadium oxide was prepared in the laboratory by calcining the precursor (ammonium metavanadate - Sigma Aldrich). Stepwise heating of the precursor was done in the presence of N<sub>2</sub> until 200 °C, then it heated until 500 °C at 5 °C min<sup>-1</sup> in the presence of O<sub>2</sub>. The dark orange color powder obtained at the end of the calcination shows the presence of V<sub>2</sub>O<sub>5</sub>.

#### 2.2 Carrier characterization

The XRD patterns of the different materials were obtained using a D8 Advanced Bruker AXS diffractometer. The wavelength of CuK $\alpha$ 1 X-ray radiation used was 1.5418 Å. The configuration for Bragg-Brentano diffractometer was theta-2 theta. The samples were immobilized on ceramic glass (Macor) holders. The angle (20) of XRD was varied between 10 and 80° with a step size of 0.02° and an integration time of 3 s.

 $N_2$  physisorption at 77 K data was collected on multipoint and single point equipment to obtain the surface area of the different catalysts before the test.

XPS analysis was performed using a Kratos Analytical AXIS UltraDLD spectrometer. A monochromatized aluminum source (AlK $\alpha$ =1486.6 eV) was used for excitation. The X-ray beam diameter is around 1 mm. The analyzer was operated in constant pass energy of 40 eV using an analysis area of approximately 700×300 µm. Charge compensation was applied to compensate for the charging effect occurring during the analysis. The C 1s (2848 eV) binding energy (BE) was used as an internal reference. The spectrometer BE scale was initially calibrated against the Ag 3d5/2 (368.2 eV) level. Pressure was in the 10<sup>-10</sup> Torr range during the experiments. Simulation of the experimental photopeaks was carried out using Casa XPS software. Quantification considered a nonlinear Shirley background subtraction.

Raman spectra were recorded at room temperature with the 647.1 nm excitation line from a Spectra Physics krypton ion laser with 3 mW laser power at the sample. The beam was focused on the compounds using the macroscopic configuration. The scattered light was analyzed with an XY 800 Raman Dilor spectrometer equipped with an optical multichannel detector (liquid nitrogen-cooled charge coupled device). The spectral resolution was approximately 0.5 cm<sup>-1</sup> in the investigated 200-1000 cm<sup>-1</sup> range.

2.3 Reactivity tests for  $H_2S$  selective oxidation.

A detailed description of the reactor setup, together with a scheme (Fig. S1), is provided in Supplementary Information. In summary, premixed gas cylinders containing 1 mol%  $H_2S$  in He and 10 mol%  $O_2$  in He were used and mixed to pure Ar. As Helium is fed together with reactants with known ratio, it serves as a diluent but also as a tracer for conversion

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calculations. For a H<sub>2</sub>S:O<sub>2</sub> ratio of 1:5, H<sub>2</sub>S/He (5 mL min<sup>-1</sup>) was passed through the reactor together with 95 mL min<sup>-1</sup> of Ar during so-called "reductant step" and O<sub>2</sub>/He (10 mL min<sup>-1</sup>) together with 90 mL min<sup>-1</sup> of Ar during so-called "oxidant step". Between these steps, 100 mL.min-1 Ar was passed through the reactor in order to maintain the reactor under a constant total flow ( $F_T$  = 100 ml min<sup>-1</sup>). For other H<sub>2</sub>S:O<sub>2</sub> ratio, the gas flow rates were adapted consequently. All flow rates were set using mass flow controllers (5980 Brooks) and reactions were performed at atmospheric pressure.

A glass tube maintained at room temperature was placed at the outlet of the reactor in order to condensate the elemental sulfur produced and to avoid plugging of the mass spectrometer inlet.

#### Table 1. Operating condition for Chemical looping process

The general operating conditions are summarized in Table 1. The concentration of the  $H_2S$  was varied from the 1000 ppm (100 Pa) to 4000 ppm (400 Pa). For most of the study  $H_2S:O_2$  was maintained at 1:5, i.e.  $O_2$  is varied from 5000 ppm (500 Pa) to 20000 ppm (2000 Pa) according to  $H_2S$  concentration.  $H_2S:O_2$  ratios of 1:2.5 and 1:0.5 were explored as well.

The temperature range explored is between 150 and 250 °C. Typically, 80 mg of  $V_2O_5$  was used and diluted in inert material (SiC). Between experiments, regeneration treatments of the carrier are performed by exposing the solid to diluted  $O_2$  (1%) and heating the sample to 400 °C for 30 minutes to fully re-oxidize the carrier and eventually remove adsorbed sulfur species. Preferential oxidation of  $H_2S$  in presence of methane was tested. 20 mL min<sup>-1</sup> was added in the reductant step and the Ar flow adjusted to maintain the total flow rate at 100 mL min<sup>-1</sup>. Reactivity of  $V_2O_5$  with respect to methane alone was also tested by exposing the OC to 20% of methane and 5% of  $O_2$  in a cyclic manner in the absence of  $H_2S$  in the 150-500°C temperature range.

In chemical looping operation, the reactivity of systems is directly linked to gas phase reactant feed (thus to concentration and flow rate), amount of carrier and duration of exposure of carrier to each reactant. Considering carrier bed volume (1 mL) and typical gas flow rate ( $F_T$  = 100 mL min<sup>-1</sup>) the gas contact time (i.e. time during which single H<sub>2</sub>S or O<sub>2</sub> molecules are exposed to solid) can be estimated to 0.6 s. On the other hand, the time during which the solid is exposed to the reactant gas is dependent on cyclic programming. In this study, each cycle consisted of exposing the sample to reductant (H<sub>2</sub>S) and oxidant (O<sub>2</sub>) for 1 min each with an interval of 2 min in Ar.

Cycles were repeated 20 or 30 times. During the first and the last cycle of the reaction, the reactor was closed to get the reference bypass value for background definition and sensitivity determination for Ar, He, H<sub>2</sub>S and O<sub>2</sub> of the online quadrupole mass analyzer (Omnistar 200, Pfeiffer Vacuum). SO<sub>2</sub> sensitivity was determined and checked regularly using a calibrated gas mixture.

Figure S2a illustrates a typical example gas phase composition evolution with time during CL operation in these experimental conditions. Figure S2b shows a detail of last cycle in presence of carrier and by-pass (reference) cycle.

Quantitative information can be obtained in different parts of the cycles. In the reductant step,  $H_2S$  conversion  $X_{H2S}$  (%) is obtained by integrating the outlet  $H_2S$  flow and comparing this to the theoretical  $H_2S$  inlet calculated using the He tracer.

$$XH_2S(\%) = \frac{(H_2S(inlet(\mu mol)) - H_2S(outlet(\mu mol)))}{H_2S(inlet(\mu mol))} x100$$
 Eq. 4

In the oxidant step,  $O_2$  conversion  $X_{02}$  (%) is obtained by integrating the outlet  $O_2$  flow and comparing this to the theoretical  $O_2$  inlet calculated from the He tracer.

$$XO_2(\%) = \frac{(O_2(inlet(\mu mol)) - O_2(outlet(\mu mol)))}{O_2(inlet(\mu mol))} x100$$
 Eq. 5

SO<sub>2</sub> can be produced in both reductant and oxidant steps. **S**<sub>SO2</sub>**R (%)** represents SO<sub>2</sub> selectivity in the reductant step (amount of SO<sub>2</sub> formed in the presence of H<sub>2</sub>S and following inert gas divided by amount of converted H<sub>2</sub>S) and is indicative of direct unselective oxidation of H<sub>2</sub>S by the oxygen carrier.

$$S_{SO2}R(\%) = \frac{SO_{2(R)}(\mu mol)}{(H_2S(inlet(\mu mol)) - H_2S(outlet(\mu mol)))} x100$$
 Eq. 6

**S**<sub>502</sub> **O** (%) represents SO<sub>2</sub> selectivity in oxidant phase (amount of SO<sub>2</sub> formed in presence of O<sub>2</sub> and following inert gas divided by amount of converted H<sub>2</sub>S and represents the oxidation of sulfur species which remain adsorbed at the surface of the carrier after the reductant step.

$$S_{SO2}O(\%) = \frac{SO_{2(O)}(\mu mol)}{(H_2S(inlet(\mu mol)) - H_2S(outlet(\mu mol)))} x100$$
 Eq. 7

As S formation cannot be monitored directly from the mass spectrometer, the selectivity towards S can only be calculated indirectly considering the total SO<sub>2</sub> formed on the overall

cycle and considering that no S accumulates on the carrier along cycling. Thus,  $S_{SO2} T$  (%) represents the total SO<sub>2</sub> selectivity:

$$S_{SO2}T = S_{SO2}R + S_{SO2}O$$
 Eq. 8

And selectivity to S is obtained as follows:

$$S = 100 - S_{SO2}T$$
 Eq. 9

Considering the amount of S and SO<sub>2</sub> produced during the reductant step, and taking into account the theoretical amount of corresponding H<sub>2</sub>O, it is possible to calculate the overall amount of O atoms involved for a single reductant step. On the other hand, the overall amount of lattice oxygen present in the OC can be calculated knowing the solid composition (i.e. V<sub>2</sub>O<sub>5</sub>). By making the hypothesis that only 1 out of 5 oxygen atoms is involved (corresponding to the reduction of V<sup>5+</sup> to V<sup>4+</sup>) one can calculate the amount of lattice oxygen ( $^{\circ}O_{latt}$ ) involved in the reductant step.

All data are obtained with a relative error margin of 5 %.

#### 3. Results

#### 3.1 Thermodynamic of $V_2O_5$ reduction by $H_2S$ and re-oxidation by $O_2$

For V<sub>2</sub>O<sub>5</sub>, the variation of Gibbs free energy of oxide reduction by H<sub>2</sub>S calculated for the numerous partially reduced phases reported in the V-O phase diagram. However, the number of partially reduced phases for which thermodynamic data is available is limited, even if the redox properties of V<sub>2</sub>O<sub>5</sub> have been already studied extensively in catalysis. Using standard Gibbs free energy ( $\Delta_f$ G°) data using FactSage database [25],  $\Delta_f$ G° have been calculated for V<sub>2</sub>O<sub>5</sub> (V<sup>5+</sup>) reduction by H<sub>2</sub>S to VO<sub>2</sub> (V<sup>4+</sup>) and V<sub>2</sub>O<sub>3</sub> (V<sup>3+</sup>) oxides considering selective (green

symbols) or total oxidation (black symbols) and represented in Figure 1 at different temperatures.

Figure 1: Variation of standard Gibbs free energy with temperature for  $H_2S$  oxidation by  $V_2O_5$ . Reduction of  $V_2O_5$  by  $H_2S$  to  $VO_2$  (closed symbols) or  $V_2O_3$  (open symbols), selective oxidation to S (green), unselective to  $SO_2$  (black), carrier re-oxidation by  $O_2$  (red), co-feed reaction in brown with  $H_2S:O_2 = 1:5$  and 1:0.5 (brown), VOSO<sub>4</sub> formation (blue)

Re-oxidation of the reduced oxides has also been considered (red symbols). Within the temperature range of interest for our experiments (150 – 250 °C), the reduction of the V<sub>2</sub>O<sub>5</sub> to VO<sub>2</sub> and V<sub>2</sub>O<sub>3</sub> by H<sub>2</sub>S producing selectively elemental S is always thermodynamically possible ant not very sensible to temperature. The re-oxidation of the corresponding reduced phases is also feasible. The  $\Delta_{\rm f}$ G° for total oxidation always significantly more exothermic than selective oxidation, meaning that the reaction kinetic will play the vital role on the overall reactivity of the system. One should also mention that the formation of vanadyl sulfate (VOSO<sub>4</sub>) is also thermodynamically feasible in the reaction conditions. Values for co-feed catalytic oxidation are also reported for comparison.

From this data, it can be concluded that in all reaction conditions explored in this work, total conversion of  $H_2S$  to  $SO_2$  will always be the most favorable reaction, both in chemical looping and co-feed modes. Furthermore, attention will need to be made on the possible formation of VOSO<sub>4</sub>.

#### **3.2.** Performances in co-feed catalytic H<sub>2</sub>S selective oxidation.

Co-feed catalytic oxidation of H<sub>2</sub>S by bulk V<sub>2</sub>O<sub>5</sub> has been performed at 150 °C and 200 °C using different H<sub>2</sub>S:O<sub>2</sub> ratio. Ratio 1:0.5 corresponds to the stoichiometric ratio for selective oxidation to elemental sulfur (Eq. 1). At such low ratio, unselective oxidation to SO<sub>2</sub> is less favored and best selectivity to H<sub>2</sub>S is expected. On the other hand, chemical looping experiments were performed at higher O<sub>2</sub> concentration (H<sub>2</sub>S:O<sub>2</sub> = 1:5). For this reason, co-feed experiments have been performed at both ratio 1:5 and 1:0.5. All co-feed performances are summarized in Table 2 while conversion/selectivity evolution with time are illustrated in Figures S3A and S3B.

Table 2. Co-feed catalytic oxidation of  $H_2S$  on bulk  $V_2O_5$ ; 80 mg  $V_2O_5 + 900$  mg SiC,  $F_T = 100$  mL min<sup>-1</sup>.

As it could be expected, bulk  $V_2O_5$  is active for  $H_2S$  oxidation and total conversion of  $H_2S$  can be observed initially in all conditions. Generally, experiments made with stoichiometric ratio show better selectivity to S compared to those performed in excess  $O_2$  in line with what is generally observed for this reaction.

In particular for excess oxygen conditions, temperature has a considerable effect on  $SO_2$  selectivity. Low temperature experiments show better performances in term of selective oxidation but suffer from rapid deactivation. In excess oxygen ( $H_2S:O_2 = 1:5$ ), 10% of conversion is lost in 30 minutes reaction time while  $SO_2$  selectivity increases significantly. Conversion then continues to decrease but selectivity remains stable. At lower oxygen feed, the deactivation process is more rapid 20% conversion loss in 30 minutes, 42% loss in 72%

minutes) but selectivity remains stable. Figures S2B indicates that the deactivation process in these conditions is complex and can involve both poisoning by S containing species and or evolution of the solid (reduction, VOSO<sub>4</sub> formation, ...).

#### 3.3. Performances in Chemical looping H<sub>2</sub>S selective oxidation.

Bulk  $V_2O_5$  has been tested in chemical looping selective oxidation of  $H_2S$  and over 20 cycles. Although at 150 and 200 °C sulfur should be in liquid state, several factors should be taken in consideration: (i) S vapor pressure is low but not negligible in the temperatures considered (approx. 200 to 2000 ppm at 150 and 200 °C, respectively), (ii) feed in  $H_2S$  (and thus S formation) in intermittent on the contrary to co-feed reaction and (iii) the actual gas temperature is probably higher than 150 or 200 °C due to the heat of reactions. These factors contribute to the vaporization of S and its condensation at the outlet of reactor in an unheated zone (glass condenser) as this could be visually observed in all cases.

 $H_2S$  conversion and selectivity to S and  $SO_2$  are represented in Figure 2. Each point represents the reactivity integrated over a full cycle.

All quantitative results in different reaction conditions are summarized in Table 3. Here, net amounts of reacted H<sub>2</sub>S and produced SO<sub>2</sub> are also indicated together with conversions and selectivity. H<sub>2</sub>S conversion remains above 80% during the experiment with a decrease of 8% with cycling. SO<sub>2</sub> is produced during both reductant and oxidant steps. In both cases, SO<sub>2</sub> production slightly decreases during the initial 5 cycles; afterward it reaches a stable value. Correspondingly the selectivity towards sulfur formation increases from 72% to 85%. Figure 2. Chemical looping oxidation of  $H_2S$ ; 80 mg  $V_2O_5$  + 900 mg SiC at 150 °C,  $F_T$  = 100 mL min, Cycle: 1 min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$  of 10000 ppm of  $O_2$  ( $H_2S:O_2$  = 1:5)

These results confirm that  $V_2O_5$  is a potential active phase for selective oxidation of  $H_2S$  in chemical looping mode, although performances clearly need to be optimized. In particular, stable and repetitive reactivity need to be obtained by better understanding the nature of the deactivation process. Furthermore, the overall selectivity to S needs to be improved by:

(i) lowering SO<sub>2</sub> formation in the reductant step and,

(ii) limiting the amount of unreacted adsorbed species which are oxidized in oxidant step forming SO<sub>2</sub>.

3.3.1 Effect of the Temperature

The evolution of the H<sub>2</sub>S conversion during the reductant step at 150 and 200 °C can be seen in Figure 3A. The evolution of selectivity is reported in Figure 3B while the overall performances during the last cycles are represented in Figure 4.

Figure 3. Chemical looping oxidation of  $H_2S$ ; 80 mg  $V_2O_5$  + 900 mg SiC at 150 °C,  $F_T$  = 100 mL min,

Cycling: 1 min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$  of 10000 ppm of  $O_2$  ( $H_2S:O_2 = 1:5$ )

A: H<sub>2</sub>S conversion, B: SO<sub>2</sub> selectivity (in reductant steps, oxidant steps and overall)

Figure 4. Chemical looping oxidation of  $H_2S$ , overall performance at 20 cycles; 80 mg  $V_2O_5$  + 900 mg SiC at 150 °C,  $F_T$  = 100 mL min<sup>-1</sup>; Cycling: 1 min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$  of 10000 ppm of  $O_2$  ( $H_2S:O_2 = 1:5$ )

Initial H<sub>2</sub>S conversion is slightly higher at 200 °C than at 150 °C, but at both temperatures, it decreases with the cycles and reaches similar values near 80%. It should be noted that this is an integrated conversion on the full exposure time to H<sub>2</sub>S. As seen in Figures 5A and 5B, during the reductant steps an evolution of the unreacted H<sub>2</sub>S is observed, specifically at 200 °C. This means that if the steps had been shorter, the integrated conversion would have given higher overall values. Regarding SO<sub>2</sub> production, as already seen previously, the overall SO<sub>2</sub> production at 150 °C decreases slightly during the first cycles then reaches stable values.

Figure 5. Detailed gas evolution during cycling; 80 mg  $V_2O_5$  + 900 mg SiC at 150 °C,  $F_T$  = 100 mL min<sup>-1</sup>; Cycling: 1 min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$  of 10000 ppm of  $O_2$  ( $H_2S:O_2$  = 1:5)

A: 150°C and B: 200°C

At high temperature (200 °C) initial selectivity to  $SO_2$  in the reductant step is very high (approx. 25 %) with respect to 150 °C (7-8%) and decreases steadily with cycling to reach approx. 17-18 % after 20 cycles. On the contrary,  $SO_2$  formed in the oxidant step starts at a very low value and increases continuously with cycling. This indicates that an increasing proportion of H<sub>2</sub>S adsorbed during reductant step is not converted to either  $SO_2$  or S in this step but oxidized to  $SO_2$  in oxidant step. This could indicate that the regeneration of the

oxygen capacity of the carrier is not complete to ensure a stable and reproducible reactivity along with cycling. Interestingly, such evolution is observed at higher temperature while it could be expected that the regeneration should be facilitated by the increase of temperature. Obviously, SO<sub>2</sub> produced in oxidant step necessarily comes from the oxidation of sulfur containing species which remained adsorbed after reductant step. The nature of these species is however not known in absolute. However, it is interesting to note that water is produced during the oxidant step meaning that the sulfur containing species which remain adsorbed between the reductant and oxidant step are not fully dehydrogenated. It is therefore more likely that H<sub>2</sub>S remain adsorbed than elemental S.

Table 3. Summary of the results for CL oxidation of  $H_2S$  in various experimental conditions; 80 mg  $V_2O_5 + 900$  mg SiC; T = 150 or 200 °C;  $H_2S$  concentration = 1000, 2000 or 4000 ppm;  $H_2S:O_2$  ratio = 1:5, 1:2.5 or 1:0.5

#### 3.3.2 Effect of the $H_2S$ concentration at 150 °C

Figure 6 shows the evolution of the activity and selectivity at 150°C at 1000, 2000, 4000 ppm of  $H_2S$  concentration along with cycling.

Figure 6. Chemical looping oxidation of  $H_2S$  with different  $H_2S-O_2$  concentrations; 80 mg  $V_2O_5$  + 900 mg SiC at 150°C,  $F_T = 100$  mL min<sup>-1</sup>; Cycling: 1 min. in  $H_2S$  (4000, 2000, 1000 ppm ) and 1 min. in  $O_2$ ( $H_2S:O = 1:5$ )

A: H<sub>2</sub>S conversion, B: SO<sub>2</sub> selectivity in reductant step, C: SO<sub>2</sub> selectivity in oxidant step, D: overall SO<sub>2</sub>

selectivity

At low concentration (1000 ppm), a high conversion of  $H_2S$  is observed with high selectivity towards the sulfur formation. A slight decrease of conversion with cycling is observed but the formation of the  $SO_2$  in the reductant and oxygen step is practically constant throughout the experiment, which illustrates the good regeneration of the catalysts during the reaction.

In terms of H<sub>2</sub>S conversion and selectivity toward SO<sub>2</sub> in the reductant step, the behavior observed at 1000 ppm of H<sub>2</sub>S is very similar to that observed at 2000 ppm already seen in previous sections. The only difference is a slightly lower selectivity to SO<sub>2</sub> in the oxidant step at lower H<sub>2</sub>S concentration indicating that less adsorbed species remains at the end of the reductant step when lower concentrations of H<sub>2</sub>S are used. On the contrary, when increasing the H<sub>2</sub>S concentration to 4000 ppm, initial conversion is high (80 %) but decreases significantly to reach a stable value around 60%. The selectivity towards SO<sub>2</sub> in the reductant step is low and remarkably similar to that observed with lower H<sub>2</sub>S concentrations. However, the amount of SO<sub>2</sub> produced in oxidant step increases strongly, indicating that the full conversion of all adsorbed species is limited in the reductant step leading to more residual sulfur containing species oxidized in the oxidant step.

Figure 7 summarizes the performances reached during the last cycles and illustrates the decrease of conversion observed at increasing H<sub>2</sub>S inlet concentration. Selectivity in reductant step does not seem affected by inlet concentration, on the contrary to SO<sub>2</sub> formation in oxidant step which increases with H<sub>2</sub>S concentration. This suggests that species adsorbed during reductant step either react to form selectively elemental sulfur and small amounts of SO<sub>2</sub>, or remain adsorbed and are converted to SO<sub>2</sub> in oxidant step. The increase in H<sub>2</sub>S concentration, in particular from 2000 to 4000 suggest that the maximum amount of H<sub>2</sub>S that can actually be converted in reductant step is reached in these conditions of carrier amount and temperature.

Figure 7. Overall performances during last cycles; 80 mg  $V_2O_5$  + 900 mg SiC at 150°C,  $F_T$  = 100 mL min<sup>-</sup>

Cycle: 1 min. in H<sub>2</sub>S (4000, 2000, 1000 ppm) and 1 min. in O<sub>2</sub>, H<sub>2</sub>S:O<sub>2</sub>- 1:5

#### 3.3.3 Effect of different reactant ratio

The effect of different ratio of reactants has been studied at 150 °C by keeping the H<sub>2</sub>S concentration at 2000 ppm and changing the oxygen concentration from 10000 ppm to 5000 ppm and 1000 ppm to achieve H<sub>2</sub>S:O<sub>2</sub> ratio of 1:5, 1:2.5 and 1:0.5 respectively. The 1:0.5 ratio corresponds to the stoichiometric one for selective oxidation of H<sub>2</sub>S (Eq. 1). The evolution of the activity and selectivity along cycling are presented in Figures 8.

For each ratio, H<sub>2</sub>S conversion varies with time (Figure 8A). In the case of ratio 1:2.5, the slope of conversion evolution with cycles is steeper than using 1:5 ratio. The initial slope of

deactivation is even steeper using the stoichiometric ratio of 1:0.5, but in this case, activity reaches a stable value after approx. 10 cycles.

Except during the very first cycles of each experiment, the selectivity towards  $SO_2$  in the reductant step is very stable and unaffected by the  $O_2$  concentration (Figure 8B).

Figure 8. Chemical looping oxidation of  $H_2S$  with different  $H_2S:O_2$  ratio, 80 mg  $V_2O_5$  + 900 mg SiC at 150°C,  $F_T = 100$  mL min<sup>-1</sup>, Cycling: 1min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$ ;  $H_2S:O_2 = 1:5$ , 1:2.5,

1:0.5

A: H<sub>2</sub>S conversion, B: SO<sub>2</sub> selectivity in reductant step, C: SO<sub>2</sub> selectivity in oxidant step, D: overall SO<sub>2</sub> selectivity

Different trends are observed for SO<sub>2</sub> formation during the oxidant step (Figure 8C). It significantly decreases at highest O<sub>2</sub> concentration (H<sub>2</sub>S:O<sub>2</sub> = 1:5) while it increases for intermediate H<sub>2</sub>S:O<sub>2</sub> ratio (1:2.5). Both these cases correspond to experiments performed in large excess of oxygen with respect to ideal reaction (Eq. 1) and, interestingly, selectivity to SO<sub>2</sub> formation in oxidant step reach similar values (12-13 %). At the lowest O<sub>2</sub> concentration (H<sub>2</sub>S:O<sub>2</sub> = 1:0.5), this selectivity it is remarkably stable around 5%. In this case, the H<sub>2</sub>S:O<sub>2</sub> ratio (1:0.5) corresponds to the stoichiometric one for selective oxidation (Eq 1) and O<sub>2</sub> conversion is actually very high (Figure 9) and could explain the low selectivity to SO<sub>2</sub> in oxidant step.

It can be noted that although the  $O_2$  concentration decreases by a factor 10 between the ratio 1:5 to the ratio 1:0.5, the overall amount of lattice oxygen involved (% $O_{latt}$ , Table 3) in the process decreases only very slightly in line with the decrease of overall conversion.

Figure 9 summarizes the performances reached during the last cycles. It indicates clearly that the selectivity towards  $SO_2$  in reductant step is not influenced by oxygen concentration in oxidant step. However, total conversion of  $H_2S$  decreases with decreasing  $O_2$  concentration suggesting that the efficiency of the regeneration in not complete in these conditions.

Figure 9. Overall performances during last cycle with different  $H_2S:O_2$  ratio; 80 mg  $V_2O_5$  + 900 mg SiC at 150°C,  $F_T$  = 100 mL min<sup>-1</sup>, Cycle: 1min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$ ;  $H_2S:O_2$  = 1:5 (20<sup>th</sup> cycle), 1:2.5 (30<sup>th</sup> cycle), 1:0.5 (30<sup>th</sup> cycle)

#### 3.3.4 Reactivity in presence of methane

The chemical looping experiments were also performed by feeding methane simultaneously with H<sub>2</sub>S during reductant step to verify if preferential oxidation of H<sub>2</sub>S could be achieved. Results obtained in similar experimental conditions with and without CH<sub>4</sub> in reductant feed are presented in Figure S4. No traces of products indicative of CH<sub>4</sub> reactivity (CO, CO<sub>2</sub>, CS<sub>2</sub>, ...) could be detected in both reductant and oxidants steps. Results show that the reactivity of the carrier is not significantly affected by the presence of methane. Actually, performances are slightly better. Initial conversions of H<sub>2</sub>S are similar at both temperatures but appear more stable in presence of methane. Selectivity to SO<sub>2</sub> formation is also slightly lower in both reductant and oxidant steps in presence of methane. Considering that a fresh carrier sample was used for these experiments and the inherent experimental margins, it is hazardous to attribute the better performances to the presence of methane. Most important is that very similar trends can be observed, in particular in terms of selectivity. Reactivity of methane alone over was tested in a similar cycling mode up to 500 °C. No measurable methane conversion could be observed within experimental error (i.e.  $Conv_{CH4} < 1\%$ ) in the full temperature range explored (150-500 °C). Some traces of CO and CO<sub>2</sub> production could be detected only at the highest temperature. This means the in the temperature range of interest for H<sub>2</sub>S selective oxidation (150-250 °C), methane is unreactive. This confirms that the preferential oxidation of the H<sub>2</sub>S in the presence of methane can be performed.

#### 4. Characterization of carriers before and after reduction and oxidation steps

The specific surface area of  $V_2O_5$  before chemical looping reaction is of 5.5 m<sup>2</sup> gr<sup>-1</sup>. It could not be measured after reaction due to the low amount of carrier used in experiments.

Samples were studied before and after reaction to evaluate the structural or chemical changes in the catalysts during the reaction. Two samples were considered by ending either after the reductant or the oxidant steps.

Different samples were submitted to CL at two temperatures (150°C and 200 °C) using 2000 ppm of  $H_2S$  with 10000 ppm of  $O_2$ . CL cycles were performed on all samples and the reaction was stopped after the  $30^{th}$  cycle either after the  $H_2S$  step or after  $O_2$  step. The reactor was then closed and cooled to room temperature. So, in total 4 samples were obtained after CL reaction:

 $V_2O_5$  (H<sub>2</sub>S, 150 °C): reaction stopped after the H<sub>2</sub>S step at 150 °C.  $V_2O_5$  (H<sub>2</sub>S, 200 °C): reaction stopped after the H<sub>2</sub>S cycle at 200 °C.  $V_2O_5$  (O<sub>2</sub>, 150 °C): reaction stopped after the O<sub>2</sub> cycle at 150 °C.

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 $V_2O_5(O_2, 200 \text{ °C})$ : reaction stopped after the  $O_2$  cycle at 200 °C.

#### 4.1. XRD

Before reaction, X-ray diffraction patterns of bulk  $V_2O_5$  shows (Figure 10) the presence of the crystalline phase of  $V_2O_5$ . Orthorhombic lattice is observed for the  $V_2O_5$  with an intense peak at  $2\Theta^\circ$  = 20.26. The intense peak represents the typical plane of (1 0 1) (JCPDF file 00-041-1426). The average crystallite size determined by XRD is 86 nm.

Figure 10. XRD of bulk  $V_2O_5$  before and after chemical looping: (•)  $V_2O_5$ , (◊)  $VO_2$ , ( $\downarrow$ )  $V_4O_5$ 

A: overall diffractogram; B: detail

A small supplementary peak at  $2\Theta$ =27.7° can be observed and could be attributed to VO<sub>2</sub> (0 1 0) plane, according to JCPDF file 04-003-2035. This peak is present at various intensities on all samples after reaction and more intensely on samples collected after reaction at 200 °C. Samples collected after reaction at 200 °C after both reductant and oxidant steps show small peaks at 2 $\Theta$  = 13.7, 21.3, 21.7, 28.1 which could indicate the presence of V<sub>4</sub>O<sub>9</sub>, [26-28] with reference to the JCPDF file 23-720. However, the small peak at 2 $\Theta$ =21.3° could also be attributed to elemental sulfur, plane (0 2 0), in reference to the JCPDF file 01-076-1100. The presence of crystalized S particles would nevertheless be rather surprising on samples collected at higher temperature and not on those collected at 150 °C as the risk of sulfur condensation and accumulation increases at lower temperature. 4.2. XPS

Before reaction, XPS spectrum of  $V_2O_5$  (Figure 11) is characterized by two photopeaks at V  $2p_{3/2}$  and V  $2p_{1/2}$  with  $\Delta E$  7.6 eV. The chemical shift observed on the photopeak V  $2p_{3/2}$  is used to distinguish the V<sup>4+</sup> and V<sup>5+</sup> species when the vanadium is found in two distinct phases and two different degrees of oxidation.  $\Delta E$  between the O 1s and V  $2P_{3/2}$  is 12.9 eV, confirming the presence of V<sup>5+</sup> oxidation state in the solid [29]. For deconvolution of V  $2P_{3/2}$ , the presence of V<sup>5+</sup> species at 517.5 eV and V<sup>4+</sup> at 516 eV are considered [30-32].

Both V<sup>4+</sup> and V<sup>5+</sup> are observed throughout the study. By the deconvolution of the different components, it is possible to estimate the ratios of V<sup>4+</sup>/ V<sup>5+</sup>, which are reported in Table 4.

Contrary to what could be expected, no significant differences in the  $V^{4+}/V^{5+}$  ratio can be observed on the samples although they were collected at different temperatures and after reductant or oxidant steps.

#### Figure 11. XPS study of V<sub>2</sub>O<sub>5</sub> before and after reaction (V2p and O1s)

Table 4. XPS analysis of samples before and after reaction, distribution of  $V^{4+}$  and  $V^{5+}$  species.

This could be explained by the fact that once the step is performed and the reactor closed, the surface oxidation state may evolve thanks to oxygen diffusion between the bulk of the solid and its surface. What seems more significant is that even after the oxidant step,  $V^{4+}$ 

species are present. This would indicate that the full oxidation to V<sup>5+</sup> does not occur even at the highest temperature.

For oxygen, the O 1s signal clearly shows three different surface oxygen species. As explained by Cornaglia et al. [31] and et al. Biesinger [33] photopeak at 530.59 eV represents the oxygen associated with the Vanadium species, the one at 530.11 eV represents the mobile oxygen in the solid and photo peak at 531.79 eV corresponds to adsorbed oxygen, hydroxyl and/or carbonate groups.

#### Figure 12. XPS study of V<sub>2</sub>O<sub>5</sub> before and after reaction (S 2p)

Practically no sulfur can be detected on these samples (Figure 12), with the exception of the sample collected after the reductant step at 150 °C. In this case, a peak at 168.8 eV is seen, providing a S/V ratio of approx. 0.02. From the position of the S2p peak, sulfate formation on the surface of  $V_2O_5$  cannot be excluded [34].

The absence of S on the sample treated at 200 °C is also surprising considering that SO<sub>2</sub> is produced during the oxidant step in these conditions. To allow this to happen, sulfur containing species must be present in the adsorbed form on the surface after the reductant step. Again, the diffusion of oxygen from the bulk, which is enhanced by temperature, could explain that these adsorbed species continue to be oxidized by the carrier during the period the reactor is closed before cooling to room temperature.

#### 4.3. Raman

The Raman spectrum of  $V_2O_5$  before and after CL reaction is shown in Figure 13. For the original carrier, the narrow peak at 997 cm<sup>-1</sup>, due to the symmetric stretching vibrations of V-O groups, is characteristic of crystalline  $V_2O_5$ . Additional bands observed near 704 cm<sup>-1</sup> arise from the stretching vibrations of V–O in the square octahedron of  $V_2O_5$ . The peaks at 146, 289, 304, 488, 704, and 997 cm<sup>-1</sup> are attributable to different crystalline  $V_2O_5$  species [27,19].

Figure 13 . Raman study of  $V_2O_5$  before and after the reaction

After reaction, all the peaks of the bulk  $V_2O_5$  are present at both the temperatures or at the last exposed reactant. However, after reaction at 200 °C, a small shoulder at 903 cm<sup>-1</sup> is observed irrespective of the last reactant present. As shown by Luan et al. [35], this peak can be assigned to bridge V-O-V chain vibrations of polymeric vanadium oxide species as these peaks feature in the 800-900 cm<sup>-1</sup> region. The peak at 903 cm<sup>-1</sup> could also show the presence of V<sup>5+</sup>-O-V<sup>4+</sup> from V<sub>4</sub>O<sub>9</sub> structure, as shown by Nieto et al. [26,27].

#### 5. Discussion

Bulk  $V_2O_5$  shows interesting activity for chemical looping oxidation of  $H_2S$  at low the temperature range of 150 to 200 °C. Experiments performed with 20, or in some case, 30, cycles show that a "steady" repetitive behavior is not always reached both in terms of  $H_2S$ 

conversion and selectivity to SO<sub>2</sub> in reductant and oxidant steps. Important trends can nevertheless be found which will allow to optimize the system.

In comparison to co-feed reactions, rather similar overall performances are observed in terms of stability (20 cycles would correspond to 20 reaction in H<sub>2</sub>S). In terms of selectivity, the overall SO<sub>2</sub> production is also rather similar. The most striking difference is that the SO<sub>2</sub> production during reductant step in CL is usually low and that in all cases the SO<sub>2</sub> formation occurs mostly during oxidant step due to excessive unreacted sulfur species remaining adsorbed after reductant step. This confirms the potential of chemical looping process to achieve better selectivity towards elemental sulfur by decoupling the two steps of reaction and avoiding direct contact between H<sub>2</sub>S and O<sub>2</sub>. However, it also illustrates the need for further optimization of CL operating conditions to avoid excess H<sub>2</sub>S adsorption with respect to the oxidation capacity of the carrier.

The conversion of the H<sub>2</sub>S varies with temperature and with different concentrations of the reactant. Considering that one V<sub>2</sub>O<sub>5</sub> unit will occupy approx. 0.21 nm<sup>2</sup>[36], taking into account the specific surface area of the solid (5.5 m<sup>2</sup> gr<sup>-1</sup>) and the amount used (80 mg), the amount of surface V<sub>2</sub>O<sub>5</sub> can be estimated to approx. 0.6  $\mu$ mol for these experiments, to be compared to 440  $\mu$ mol of total V<sub>2</sub>O<sub>5</sub>. As seen in Table 3, the percentage of lattice oxygen involved varies between 0.9 and 2.2 % O<sub>latt</sub>, i.e. between 4 and 16  $\mu$ mol, which would represent the involvement of 6 to 16 layers of V<sub>2</sub>O<sub>5</sub>. This is obtained considering exclusively the reduction of V<sup>5+</sup> species to V<sup>4+</sup> and the numbers of layers involved would clearly be smaller if a reduction to V<sup>3+</sup> takes place. In any case, this indicates that both surface species and subsurface layers of the oxide are involved to account for the reactivity of the system.

It was observed that in all cases, some SO<sub>2</sub> is formed during the reductant step. The amount  $(SO_2R)$  varies from 0.1 to 1.1 µmol (Table 3) according to reaction conditions. These values are in the same order of magnitude as that of surface V<sub>2</sub>O<sub>5</sub> calculated above and could suggest that the outermost oxidized vanadium species generated during the re-oxidation result in unselective oxidation. However, in this case, this amount should not vary significantly. On the contrary, as seen, the amount of SO<sub>2</sub>R increases significantly with temperature and is also affected by the concentration of H<sub>2</sub>S, in particular at 150 °C.

Another way to explain this is that certain surface planes exposed by the solid lead to unselective oxidation, which can then proceed more deeply through subsurface layers according to temperature and H<sub>2</sub>S pressure, while other planes would show better selectivity. This anisotropic behavior of crystalline oxides has already been observed for several selective oxidation reactions [37,38].

The contribution of deep subsurface layers of the oxide is coherent with the presence of both  $V^{4+}$  and  $V^{5+}$  species on all samples after the experiment, independently of reaction temperature and of the nature of the last step before recovering the sample. If the presence of  $V^{4+}$  species could be expected after the reductant step, it was more surprising after the oxidant one. However, if one considers that the subsurface layers are progressively involved during cycling, it is possible that the re-oxidation does not proceed so deeply at each cycle. If reduced species are still present, the solid would slowly re-equilibrate by diffusion of oxygen species from surface towards the bulk. Inversely, deeper oxygen species from the bulk may migrate to the subsurface in samples recovered after the reductant step.

On the other hand, XRD and Raman show the formation of  $V_4O_9$  phase on samples tested at 200°C. This phase is observed on samples collected after both reductant and oxidant steps. This indicates a structural modification of the sample during cycling which seems to be favorized by higher temperature and thus mobility of oxygen species in the solid. This  $V_4O_9$  phase has been observed and identified as responsible for selective oxidation of  $H_2S$  in co-feed conditions [26]. One could therefore suppose that the solid is progressively reduced from  $V_2O_5$  to  $V_4O_9$  during cycling. At this point, the carrier phase would retain a good selectivity to oxidize  $H_2S$  to S in reductant step generating low amounts of  $SO_2$  in this step. However, by reducing the amount of  $V^{5+}$  species available to perform such oxidation, thus reducing the oxygen capacity of the carrier, more adsorbed species remain unreacted at the end of reductant step and are subsequently oxidized to  $SO_2$  in oxidant step.

This result shows that the transient nature of the process must always be considered when comparing results considering that the solid continues to evolve between reaction steps, where it is submitted to external "stress", and relaxation periods.

This could also be featured regarding the presence of sulfur species on samples after the test. No S could be detected by XPS even on sample treated at 200 °C after H<sub>2</sub>S exposure. Although S should be present after such cycling, its absence during characterization suggests that it continues to be converted by the solid.

Finally, the preferential oxidation of  $H_2S$  in the presence of methane is confirmed in line with results obtained by Palma et al [5] on ceria supported vanadium oxide catalyst for abatement of  $H_2S$  from biogas at low temperature. They achieved preferential oxidation of  $H_2S$  in presence of methane and carbon dioxide with no byproducts such as  $COS_2$ ,  $CS_2$  observed

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during the reaction. The major difference is that  $O_2$  needed to be co-fed with the biogas which involve serious safety limitations for practical development at large scale. In this respect, chemical looping offers the advantage of avoiding dangerous mixtures.

The absence of reactivity of methane in these conditions is not a surprise as for most catalytic reaction using oxide-based catalysts, much higher reaction temperatures are needed. For example, in the case of V based catalysts, temperature between 550 and 650 °C had to be used for the oxidation of methane to formaldehyde on silica supported V as shown by Loricera et al.[39] or Nguyen et al.[40].

#### 6. Conclusions

The concept of chemical looping was implemented for the first time for selective oxidation of  $H_2S$ . The results confirm that  $V_2O_5$  is a potential candidate as an active phase in oxygen carriers for this reaction. They show that  $H_2S$  can be selectively converted to elemental S on such materials, which further demonstrate to have interesting cyclic regeneration properties both in terms of oxygen capacity and surface sulfur species removal.

It can be confirmed that not only outermost surface species are involved in the redox process. Indeed, rather deep reduction/oxidation of the solid is possible even at such low reaction temperature and the formation of  $V_4O_9$  phase appears to be significant in determining the performances of the carrier. However, the transient nature of chemical looping processes makes a further hypothesis on the reaction mechanism highly hypothetical at this point.

In most conditions explored, selectivity to elemental sulfur is high, although some  $SO_2$  is formed during the reductant cycle. Actually, most of the  $SO_2$  is produced during the oxidant

step. This confirms the interest for decoupling the two reaction steps by chemical looping. However, improvements remain to be done to enhance the reactivity of the active phase in order to limit the presence of unreacted or partially unreacted species adsorbed during the reductant step. Another crucial aspect is the stability of the performances along cycling which needs to be achieved either by the design of better carriers or by optimizing the operating conditions.

In line with the well-known activity of  $V_2O_5$  in co-feed selective oxidation of  $H_2S$  and with the thermodynamic considerations, these results confirm that vanadium oxide materials can effectively be considered as active carriers in such novel chemical looping process and which allows having selective and preferential oxidation of  $H_2S$  to S.

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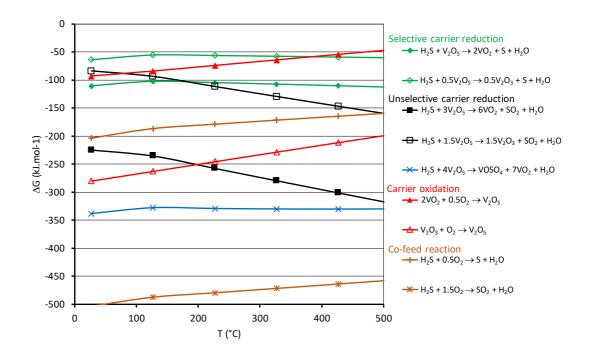


Figure 1: Variation of standard Gibbs free energy with temperature for  $H_2S$  oxidation by  $V_2O_5$ . Reduction of  $V_2O_5$  by  $H_2S$  to  $VO_2$  (closed symbols) or  $V_2O_3$  (open symbols), selective oxidation to S (green), unselective to  $SO_2$  (black), carrier re-oxidation by  $O_2$  (red), co-feed reaction in brown with

 $H_2S:O_2 = 1:5$  and 1:0.5 (brown),  $VOSO_4$  formation (blue)

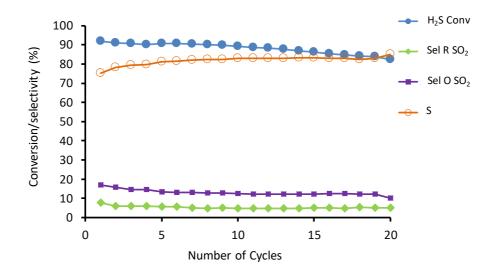


Figure 2. Chemical looping oxidation of  $H_2S$ ; 80 mg  $V_2O_5$  + 900 mg SiC at 150 °C,  $F_T$  = 100 mL min<sup>-1</sup>, Cycle: 1 min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$  of 10000 ppm of  $O_2$  ( $H_2S:O_2$  = 1:5)

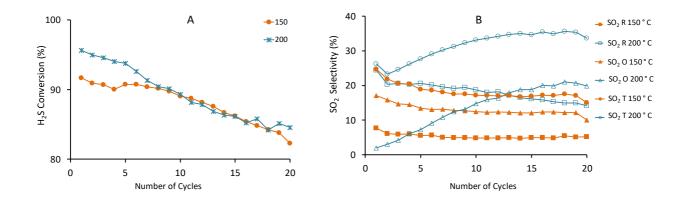


Figure 3. Chemical looping oxidation of  $H_2S$ ; 80 mg  $V_2O_5$  + 900 mg SiC at 150 °C,  $F_7$  = 100 mL min<sup>-1</sup>, Cycling: 1 min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$  of 10000 ppm of  $O_2$  ( $H_2S:O_2$  = 1:5) A:  $H_2S$  conversion, B:  $SO_2$  selectivity (in reductant steps, oxidant steps and overall)

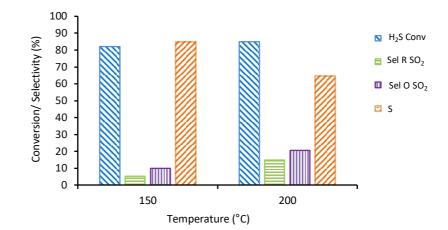


Figure 4. Chemical looping oxidation of  $H_2S$ , overall performance at 20 cycles; 80 mg  $V_2O_5$  + 900 mg SiC at 150 °C,  $F_T$  = 100 mL min<sup>-1</sup>; Cycling: 1 min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$  of 10000 ppm of

 $O_2 (H_2 S: O_2 = 1:5)$ 

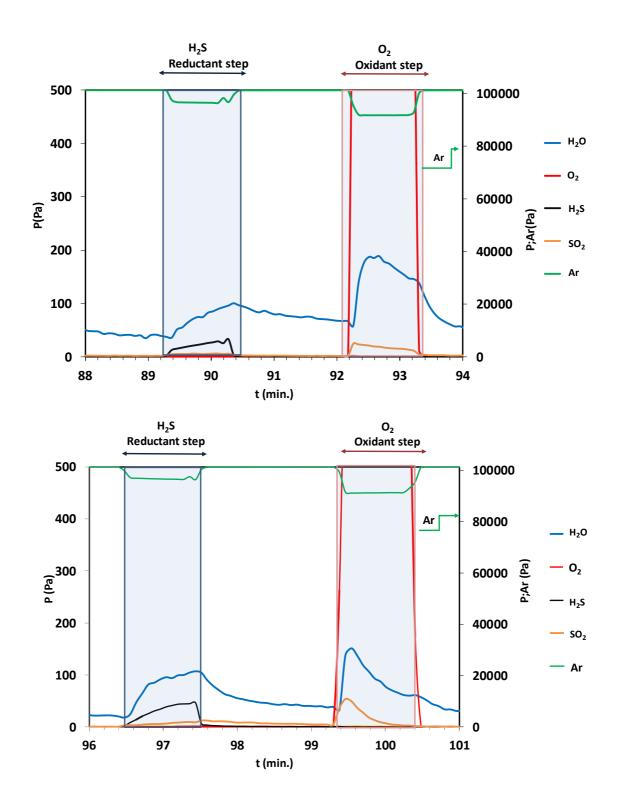
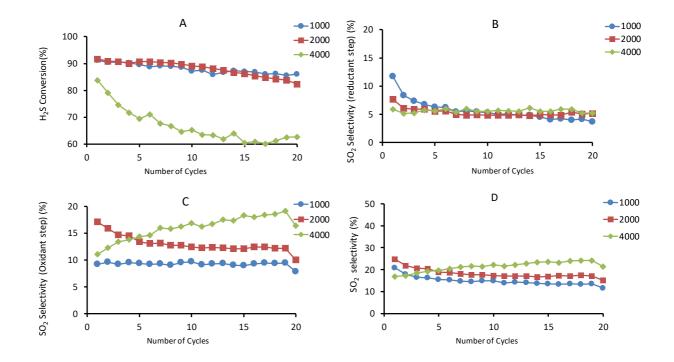
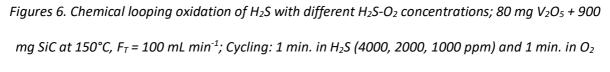


Figure 5. Detailed gas evolution during cycling; 80 mg  $V_2O_5$  + 900 mg SiC at 150 °C,  $F_7$  = 100 mL min<sup>-1</sup>; Cycling: 1 min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$  of 10000 ppm of  $O_2$  ( $H_2S:O_2$  = 1:5)

A: 150°C and B: 200°C





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(H_2S:O = 1:5)
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A: H<sub>2</sub>S conversion, B: SO<sub>2</sub> selectivity in reductant step, C: SO<sub>2</sub> selectivity in oxidant step, D: overall SO<sub>2</sub>

selectivity

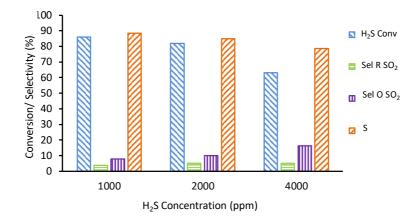


Figure 7. Overall performances during last cycle (20<sup>th</sup>) with different H<sub>2</sub>S-O<sub>2</sub> concentrations; 80 mg  $V_2O_5$  + 900 mg SiC at 150°C,  $F_T$  = 100 mL min<sup>-1</sup>;

Cycling: 1 min. in  $H_2S$  (4000, 2000, 1000 ppm) and 1 min. in  $O_2$  ( $H_2S:O_2 = 1:5$ )

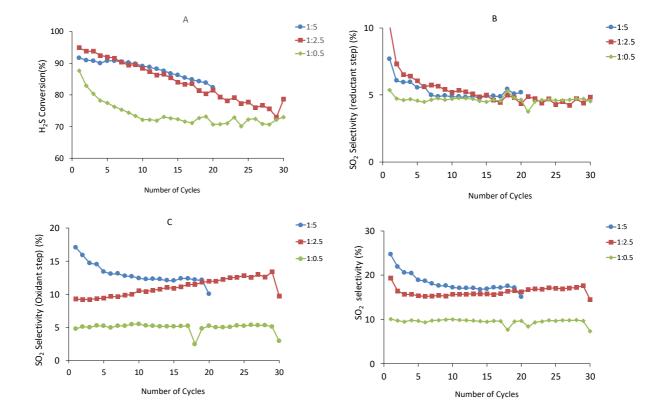


Figure 8. Chemical looping oxidation of  $H_2S$  with different  $H_2S:O_2$  ratio, 80 mg  $V_2O_5$  + 900 mg SiC at 150°C,  $F_T = 100$  mL min<sup>-1</sup>, Cycling: 1min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$ ;  $H_2S:O_2 = 1:5$ , 1:2.5,

1:0.5

A: H<sub>2</sub>S conversion, B: SO<sub>2</sub> selectivity in reductant step, C: SO<sub>2</sub> selectivity in oxidant step, D:

overall SO<sub>2</sub> selectivity

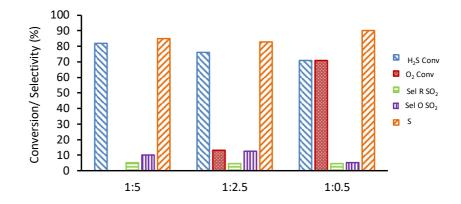


Figure 9. Overall performances during last cycle with different  $H_2S:O_2$  ratio; 80 mg  $V_2O_5$  + 900 mg SiC at 150°C,  $F_T = 100$  mL min<sup>-1</sup>, Cycle: 1min. in 2000 ppm of  $H_2S$ , and 1 min. in  $O_2$ ;  $H_2S:O_2 = 1:5$  (20<sup>th</sup> cycle), 1:2.5 (30<sup>th</sup> cycle), 1:0.5 (30<sup>th</sup> cycle)

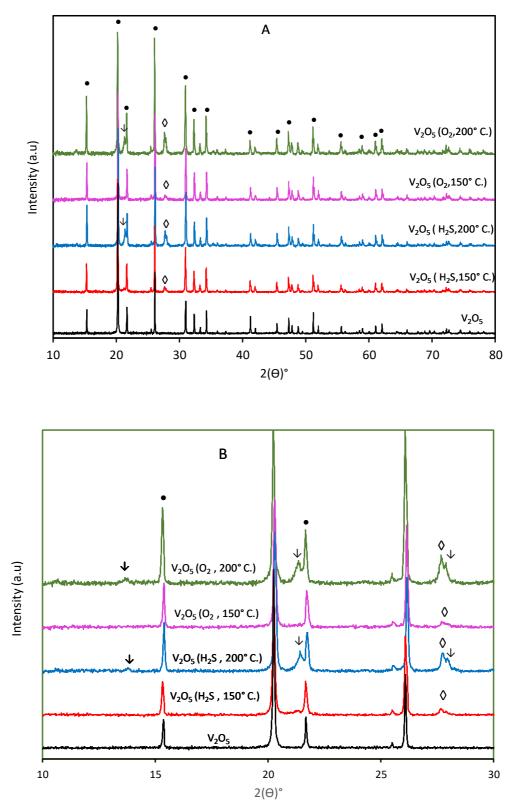


Figure 10. XRD of bulk  $V_2O_5$  before and after chemical looping: (•)  $V_2O_5$ , (◊)  $VO_2$ , ( $\downarrow$ )  $V_4O_5$ A: overall diffractogram; B: detail

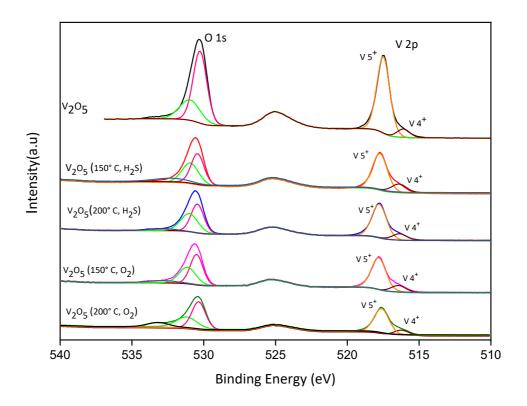


Figure 11. XPS study of  $V_2O_5$  before and after reaction (V2p and O1s)

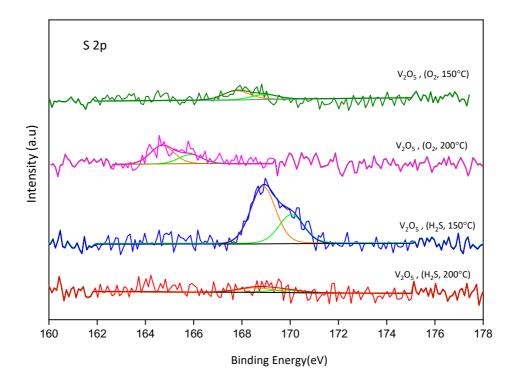


Figure 12. XPS study of  $V_2O_5$  before and after reaction (S 2p)

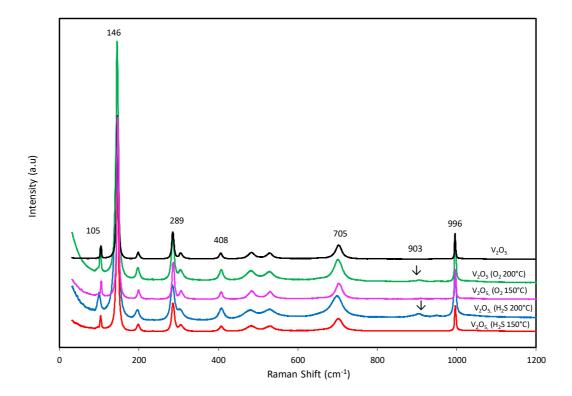


Figure 13. Raman study of  $V_2O_5$  before and after the reaction

Operating Conditions	
Temperature	150-200 °C.
Carrier amount	80 mg V <sub>2</sub> O <sub>5</sub> + 900 mg SiC
H <sub>2</sub> S Concentration	1000, 2000, 4000 ppm
H <sub>2</sub> S:O <sub>2</sub>	1:5, 1:2.5, 1:0.5
CH4 (vol %)	20%
Cyclic operation	Step 1: 1 min in H <sub>2</sub> S + He + Ar Step 2: 2 min in Ar Step 3: 1 min in O <sub>2</sub> + He + Ar Step 4: 2 min in Ar
Total flow	100 mL min <sup>-1</sup>

Table 1. Operating condition for Chemical looping process

				T0 (min)		T30 (min)			T90 (min)			
Temp	H₂S	O <sub>2</sub>	H₂S:O₂	H₂S	02	SO₂	H₂S	02	SO <sub>2</sub>	H <sub>2</sub> S	02	SO <sub>2</sub>
				Conv.	Conv.	Sel.	Conv.	Conv.	Sel.	Conv.	Conv.	Sel.
(°C)	ppm	ppm		(%)	(%)	(%)	(%)	(%)	(%)	(%)	(%)	(%)
150	2000	10000	1:5	98	10	1.8	89	68	13	75	7	13
200	2000	10000	1:5	98	25	31	98	18	27	97	17	24
150	2000	1000	1:0.5	97	96	1.4	77	64	4.7	45*	54*	6*
200	2000	1000	1:0.5	99	94	1.8	96	94	6.7	97	97	7.2

\* Actual reaction time is 71 min,

Table 2. Co-feed catalytic oxidation of  $H_2S$  on bulk  $V_2O_5$ ; 80 mg  $V_2O_5$  + 900 mg SiC,  $F_T$  = 100 mL min<sup>-1</sup>.

H <sub>2</sub> S Concentration (ppm)	2000	2000	1000	4000	2000	2000
Temperature (°C)	150	200	150	150	150	150
H <sub>2</sub> S:O <sub>2</sub>	1:5	1:5	1:5	1:5	1:2.5	1:0.5
H₂S feed per cycle (µmol)	8.6	8.6	4.7	16.5	8.6	8.6
Conv H <sub>2</sub> S (%)	82	85	86	63	76	71
H₂S converted (µmol)	7.1	7.3	4.0	10.4	6.5	6.1
S (μmol)	5.9	4.7	3.6	8.1	5.4	5.5
SO₂R (µmol)	0.4	1.1	0.1	0.5	0.3	0.3
SO₂O (µmol)	0.7	1.5	0.3	1.7	0.8	0.3
(S/S+SO <sub>2</sub> R) (%)	94	81	96	94	95	95
%O <sub>latt</sub> (% V <sup>5+</sup> -> V <sup>4+</sup> )	1.6	1.8	0.9	2.2	1.4	1.4

Table 3. Summary of the results for CL oxidation of  $H_2S$  in various experimental conditions; 80 mg $V_2O_5 + 900$  mg SiC; T = 150 or 200 °C;  $H_2S$  concentration = 1000, 2000 or 4000 ppm;  $H_2S:O_2$  ratio = 1:5,

1:2.5 or 1:0.5

Carrier		(eV) 2p	V <sup>4+</sup> / (V <sup>4+</sup> +V <sup>5+</sup> )	V <sup>5+</sup> / (V <sup>4+</sup> +V <sup>5+</sup> )	V <sup>4+</sup> /V <sup>5+</sup>	s/v
	V <sup>4+</sup>	V <sup>5+</sup>	_ (0 .0 )	(••••)		
V <sub>2</sub> O <sub>5</sub>	516.09	517.49	0.065	0.93	0.071	-
$V_2O_5  150  ^\circ C  H_2S$	516.39	517.73	0.18	0.82	0.22	0.02
$V_2O_5 200 \ ^\circ C H_2S$	516.33	517.78	0.15	0.85	0.17	-
V <sub>2</sub> O <sub>5</sub> 150 °C O <sub>2</sub>	515.97	517.39	0.17	0.83	0.19	
V <sub>2</sub> O <sub>5</sub> 200 °C O <sub>2</sub>	516.17	517.62	0.19	0.81	0.23	-

Table 4. XPS analysis of samples before and after reaction, distribution of  $V^{4+}$  and  $V^{5+}$  species.

## **Supplementary Information**

## $H_2S$ chemical looping selective and preferential oxidation to sulfur by bulk $$V_2O_{5}$$

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## 2. Experimental sections

2.3 Reactivity tests for  $H_2S$  selective oxidation.

## Additional detailed experimental setup description

The reactor setup is represented in Figure S1.

The reactor is U shaped quartz tube (6 mm O.D.) and a larger space (12mm O.D., 10mm I.D.) containing a fritted disc defining a volume of approx. 2 mL in which the catalyst/oxygen carrier is placed. The reactor is placed in a temperature regulated furnace. A thermocouple is placed against the outer wall of the reactor at the catalyst/carrier level for temperature recording.

A Pyrex glass tube (4 mm I.D.) is connected directly to the quartz reactor outlet in order to condense the sulfur produced during reaction ("Glass condenser"). This condenser was regularly replaced and cleaned to avoid plugging by condensed sulfur.

The reactor section composed of the reactor itself and glass condenser can be closed using 4way valve V1. A second condenser is placed downstream of the reactor in order to ensure that no trace of sulfur remain that could be condensed in the analytical instrument. All lines (1/8" tubing) from V1 to the analytical instruments are heated at 200 °C (heating cords).

Gas streams are set using 6 mass flow controllers (MFC, Brooks 5980). MFC's n. 1, 4 and 6 are fed with Argon; MFC2 with  $H_2S/He$  mixture (premixed cylinder); MFC5 with  $O_2/He$  mixture (premixed cylinder) and MFC3 with pure methane (99.995%).

In *chemical looping mode*, 4-way valve V3 is fed by Ar (MFC1) and H<sub>2</sub>S/He (MFC2) streams with equivalent flow rates. Similarly, V4 is fed by Ar (MFC6) and O<sub>2</sub>/He (MFC5) streams with equivalent flow rates. Streams coming from V3 and V4 are then mixed with another Ar stream (MFC4). This allows to adjust "reductant" and "oxidant" concentrations independently in a wide range.

All 4-way valves (V1 to V4) are equipped with air actuators. During looping operation, valves V3 and V4 are operated sequentially using a homemade control system and software.

At all time the flow rate at reactor inlet is constant as it is composed of three components

Total flow = MFC4 + (MFC1 or MFC2) + (MFC5 or MFC6)

In co-feed mode, both V3 and V4 are switched to feed reactant gases together.

In preferential oxidation tests in presence of methane, a methane stream is added to the reductant line feeding V3 and Argon flows (MFC1 and MFC4) are adapted consequently.

In both reductant and oxidant steps, the He contained in the premixed cylinders acts as a tracer of the reactant stream.

Before and after each chemical looping sequence, a cycle is performed with reactor closed (V1 in by-pass position). This allows to calibrate the  $H_2S$ ,  $O_2$  and He responses. During reacting cycles (V1 in open reactor position)  $H_2S$  conversion can be determined by calculating the theoretical  $H_2S$  inlet curve using the He one.

Figure S2-A illustrates a typical example partial pressure evolution with time during Chemical Looping operation in these experimental conditions. Figure S2-B shows a detail of last cycle in presence of carrier and by-pass (reference) cycle.

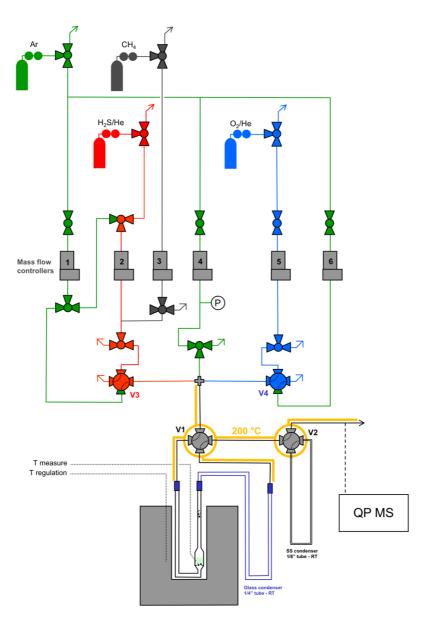


Figure S1. Reactor setup scheme

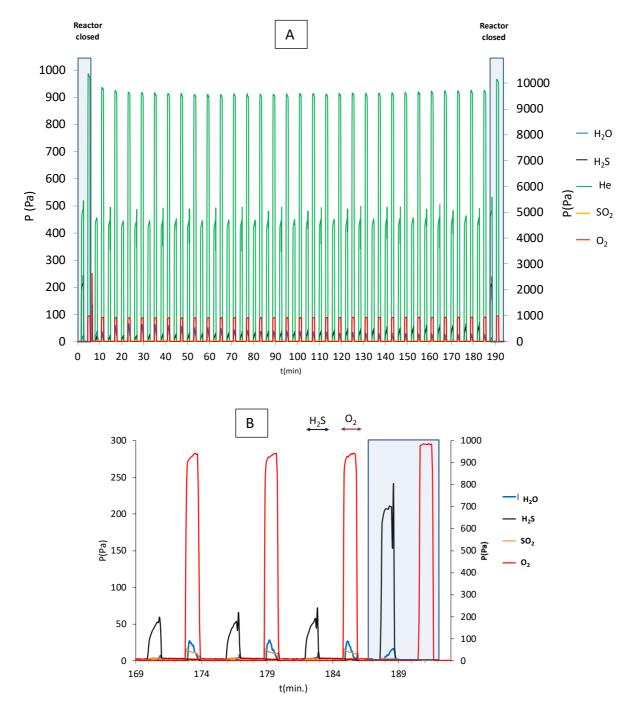
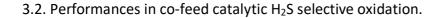


Figure S2. Partial pressures evolution during  $H_2S - O_2$  cycling  $80 \text{ mg } V_2O_5 + 900 \text{ mg SiC}$  at 150 °C,  $F_T = 100 \text{ mL min}^{-1}$ Cycle: 1min. in 2000 ppm (200 Pa) of  $H_2S$  and 1 min. in 10000 ppm (1000 Pa) of  $O_2$   $H_2S:O_2 = 1:5$ A: overall view on full experiment (30 cycles) B: detail of partial pressure evolution for the last 3 cycles.



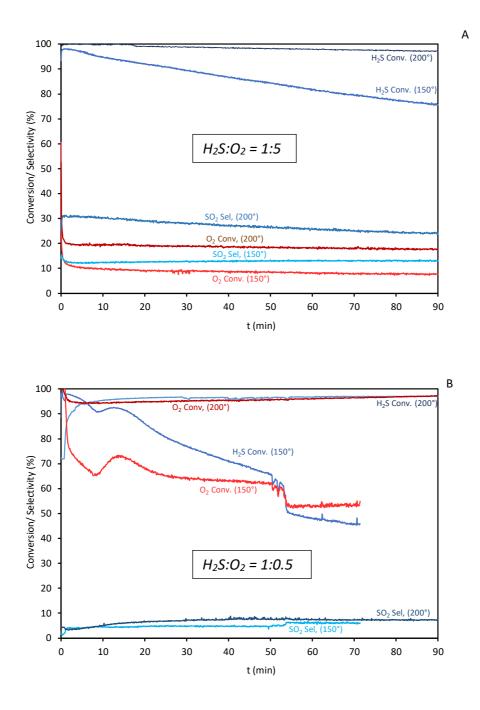


Figure S3. Evolution of  $H_2S$  and  $O_2$  conversion and  $SO_2$  selectivity in co-feed  $H_2S$  oxidation 80 mg  $V_2O_5$  + 900 mg SiC at 150 °C and 200 °C,  $F_7 = 100$  mL min<sup>-1</sup>, A:  $H_2S:O_2 = 1:5$  (2000 ppm of  $H_2S$ , and 10000 ppm of  $O_2$ ,) B:  $H_2S:O_2 = 1:0.5$  (2000 ppm of  $H_2S$ , and 1000 ppm of  $O_2$ )

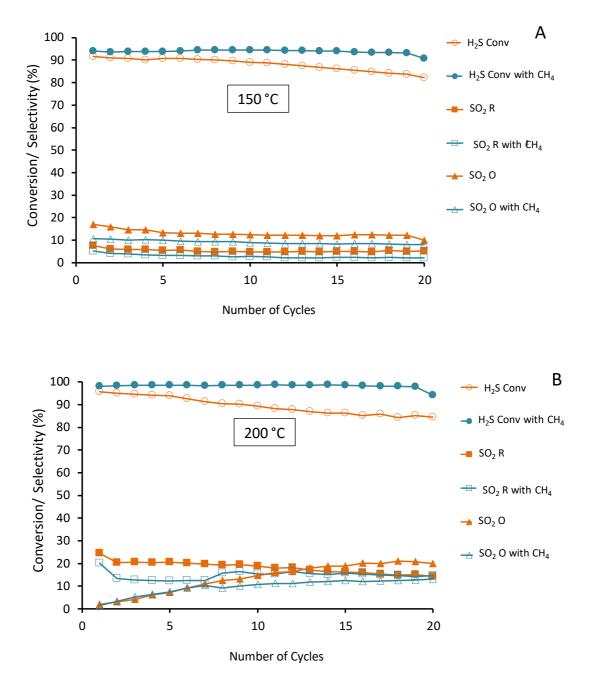


Figure S4. Chemical looping preferential oxidation of H<sub>2</sub>S in presence of CH<sub>4</sub> 80 mg V<sub>2</sub>O<sub>5</sub> + 900 mg SiC, F<sub>T</sub> = 100 mL min<sup>-1</sup>, 2000 ppm of H<sub>2</sub>S, H<sub>2</sub>S:O<sub>2</sub> = 1:5, CH<sub>4</sub> = 20 % Closed symbol (•) without CH<sub>4</sub>, open symbol (o) with CH<sub>4</sub> A: T=150° C

B: T=200 °C